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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/081,426	02/22/2002	Rajendra Solanki	D8848-02	2992
25397 75	590 05/18/2004		EXAMINER	
DUANE, MORRIS, LLP			FULLER, ERIC B	
SUITE 3150 3200 SOUTHWEST FREEWAY			ART UNIT	PAPER NUMBER
HOUSTON, TX 77046			1762	
			DATE MAILED: 05/18/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
••	10/081,426	SOLANKI ET AL				
Office Action Summary	Examiner	Art Unit				
,	Eric B Fuller	1762				
The MAILING DATE of this communication ap	I .					
Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a replection of the period for reply is specified above, the maximum statutory period. - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be timely within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from e, cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 29 A	April 2004.					
2a) This action is FINAL . 2b) ⊠ This	s action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4) Claim(s) 1-14 and 20-24 is/are pending in the 4a) Of the above claim(s) is/are withdra 5) Claim(s) is/are allowed. 6) Claim(s) 1-14 and 20-24 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or Application Papers 9) The specification is objected to by the Examine	ovn from consideration. or election requirement. er.					
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documen 2. Certified copies of the priority documen 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	ts have been received. ts have been received in Applicationity documents have been received in (PCT Rule 17.2(a)).	on No ed in this National Stage				
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:					

Application/Control Number: 10/081,426

Art Unit: 1762

DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of Group I, claims 1-14 and 20-24, is acknowledged. Applicant has canceled claims 15-19.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 3-14, 20, 21, 23, and 24 rejected under 35 U.S.C. 103(a) as being unpatentable over Elers et al. (US 6,475,276 B1) in view of Norman et al. (US 5,322,712) and Rangarajan et al. (US 6,444,038 B1).

Elers teaches an ALD method of forming a copper or silver coating on a silicon substrate that has a TiN barrier layer (column 5, lines 1-35). The precursors are the same as the applicant's claims (column 5, lines 55-60). The process steps are taught in column 4, lines 19-28. The thickness is taught in column 3, line 6. The reference is silent to bubbling the carrier gas through water.

However, Norman teaches that water vapor can accelerate deposition of copper from similar precursors (column 5, lines 45-60). Therefore, to include water in the in the carrier gas would have been obvious at the time the invention was made to a person

Application/Control Number: 10/081,426

Art Unit: 1762

having ordinary skill in the art with the expectation of achieving accelerated deposition. Additionally, Rangarajan teaches a bubbler used for a vapor deposition process that has the advantage of providing a stable supply of feed material (column 1, lines 30-35; column 2, lines 23-45). Therefore, it would have been obvious at the time the invention was made to a person having ordinary skill in the art to utilize the bubbler of Rangarajan in the process taught by Elers, in view of Norman, with the expectation of providing a stable supply of water vapor to the reaction chamber.

Elers fails to explicitly teach the feed times for each reactant and purge gas.

However, it would have been within the skill of one practicing in the art to determine the feed times required such that a uniform monolayer is formed on the substrate and/or the reaction space is sufficiently purged.

Claims 2 and 22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Elers et al. (US 6,475,276 B1) in view of Norman et al. (US 5,322,712) and Rangarajan et al. (US 6,444,038 B1), as applied to claims 1 and 21 above, and further in view of Cho (US 5,087,485).

Elers, in view of Norman and Rangarajan, teach the limitations above, but fails to explicitly teach using alcohol as the reducing agent. However, Cho teaches using isopropanol for reducing copper precursors in a vapor deposition process. It would have been obvious at the time the invention was made to a person having ordinary skill in the art to utilize isopropanol as a reducing agent in the process taught by Elers. By doing so, one would have a reasonable expectation of success, as Cho teaches the art

Application/Control Number: 10/081,426

Art Unit: 1762

1762

recognized suitability of using isopropanol to reduce copper precursors for a vapor deposition process.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eric B Fuller whose telephone number is (571) 272-1420. The examiner can normally be reached on Mondays through Thursdays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Shrive P Beck, can be reached on (571) 272-1415. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

TIMOTHY MEÉKS PRIMARY EXÁMINER

EBF